

DNAG-228

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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant(s) : AMIRZADEH-ASL, et al.  
Based on: PCT/EP00/02872  
International Filing Date : March 31 2000  
For : METHOD FOR PRODUCING BARIUM SULFATE, BARIUM SULFATE AND THE UTILIZATION THEREOF

Hon. Commissioner of Patents  
and Trademarks  
Washington, D.C. 20231

December 3, 2001

**INFORMATION DISCLOSURE STATEMENT**

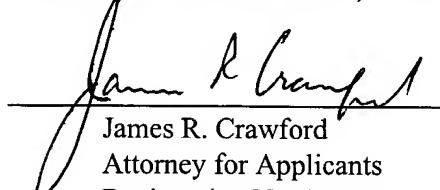
Sir:

In accordance with their duty of disclosure, applicants wish to make the referenced cited in the enclosed PTO-Form-1449 of record in this application. These references were cited in the International Search Report. It is believed that copies of these references in the international search report have already been provided by the ISA.

Applicants believe no fee is required for filing these papers. However, the Commissioner is hereby authorized to deduct any fee due, or credit any overpayment to Deposit Account No. 50-0624.

Respectfully submitted,

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

(37 CFR 1.98(b))

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APPLICANT

Amirzadeh-Asl, et al.

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FILING DATE

GROUP

To Be Assigned

**U.S. PATENT DOCUMENTS**

*Examiner Initial	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date (if appropriate)	
	Document Number	Date	Country	Class	Subclass	Translation	
						Yes	No
	0 687 651	12/20/95	EP				
	0 371 530	6/6/90	EP				
	22 46 818	3/28/74	DE				
	21 34 646	3/2/72	DE				
	0 445 785	9/11/91	EP				

**OTHER DOCUMENTS**

(INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

	Chemical Abstracts, Vol.119, No. 4, 7/26/93 & JP 05 058624 - 3/9/93
	Chemical Abstracts. Vol. 121. No. 24, 12/12/94 - and JP 06 234518 - 8/23/94

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.